

# Toward Graphene Integration from the Bottom-Up

Dr. Patrick Han

Assistant Professor

Advanced Institute for Materials Research, Tohoku University

E-mail: han.patrick.b7@tohoku.ac.jp

Since 2010, graphene has been expected to revolutionize, or at least to enhance silicon-based nanoelectronics. However, the current, fragmented directions of graphene research cannot reach this goal, in part because of the (frustrating) lack of a band gap in graphene, and also because of the lack of connection technique for graphene. Fabricating graphene nanoribbons (GNRs) by molecular assembly is a strategy that promises both to tune graphene's band gap by width control, and to connect the tailored GNR properties to desired contacts by length control. In this talk, I will first discuss the current state of GNR research: from its initial, revolutionary promises, to its present experimental difficulties. Then I will discuss a new bottom-up molecular assembly process,<sup>1,2</sup> which uniquely uses the properties of the supporting substrate: 1) to control the molecular-assembly chemistry, and 2) to interconnect the product GNRs both chemically and electronically. Finally, I posit that these results illuminate the unexplored potential of bottom-up strategies for obtaining atomically precise graphene nanostructures that are well connected to desired contacts—the crucial step toward the integration of graphene and silicon-based nanoelectronics.

## References

1. Han, P.; Akagi, K.; Canova, F. F.; Mutoh, H.; Shiraki, S.; Iwaya, K.; Weiss, P. S.; Asao, N.; Hitosugi, T., Bottom-Up Graphene-Nanoribbon Fabrication Reveals Chiral Edges and Enantioselectivity, *ACS Nano* 8, 9181-9187, (2014).
2. Han, P.; Akagi, K.; Federici Canova, F.; Shimizu, R.; Oguchi, H.; Shiraki, S.; Weiss, P. S.; Asao, N.; Hitosugi, T., Self-Assembly Strategy for Fabricating Connected Graphene Nanoribbons, *ACS Nano* 9, 12035-12044, (2015).